## Claims

## What is claimed is;

A process for the manufacture of compounds of the formula

R<sup>2</sup>O NHR<sup>1</sup>

wherein R<sup>1</sup> and R<sup>2</sup> are independently an acyl residue of an aromatic carboxylic acid,

10 comprising:

a) asymmetrically hydrogenating a compound of the formula

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wherein R<sup>3</sup> is lower-alkyl, to a compound of the formula

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b) providing a protecting group to the compound of formula  $1\sqrt{2}$ 

s) saponifying the compound of formula IV after step b), forming a compound of the formula

wherein R4 is a protecting group;

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d) converting the compound of formula V into a compound of the formula

CO NH VI;

e) hydrolyzing the compound of formula VI into a compound of the formula

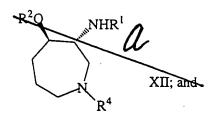
HO NH<sub>2</sub> VII;

f) N- and, respectively, O-acylating the compound of formula VII with an aromatic carboxylic acid of the formula R¹COOH or R²COOH to form a compound of the formula

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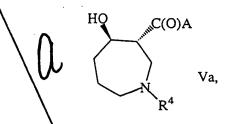


g) cleaving off protective groups on the compound of formula XII, to form the compound of formula I.

2. The process of claim 1, wherein  $R^1$  and  $R^2$  are phydroxybenzoyl.

3. The process of claim 1, further comprising in step c

i) converting the compound of formula V into a compound of the formula



wherein A is azido or amino; and

ii) performing a Curtius or Hofmann degradation on the compound of formula Va to yield the compound of formula VI.

4. The process of claim 1, wherein the compound of formula II is hydrogenated in the presence of a rhodium-diphosphine complex catalyst having a formula selected from the formulae

	<b>W</b> herein	
	1	the group consisting of BF <sub>4</sub> -, ClO <sub>4</sub> -,
	•	4 <sup>-</sup> , SbF <sub>6</sub> <sup>-</sup> , PF <sub>6</sub> <sup>-</sup> and Z <sup>1</sup> -SO <sub>3</sub> <sup>-</sup> ;
	X <sup>1</sup> √ is halide;	
5		amethylbenzene or p-cymene;
		the group consisting of halide, ClO <sub>4</sub> -,
		<sub>4</sub> -, SbF <sub>6</sub> -, PF <sub>6</sub> -, Z <sup>1</sup> -SO <sub>3</sub> - and BF <sub>4</sub> -; the group consisting of Z <sup>2</sup> -COO-, Z <sup>3</sup> -
٠	<i>f</i>	and CH <sub>3</sub> COCH=C(CH <sub>3</sub> )O-;
10	\ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \ \	ower alkyl or halogenated
	phenyl;	
	Z <sup>2</sup> is selected from	the group consisting of lower alkyl,
	· 1	logenated lower alkyl and halogenated
4 5	phenyl;	
15	Z <sup>3</sup> is lower alkyl or L is an optically	pnenyi; and active atropiso-meric, diphosphine ligand.
	is an opticative	active attopiso-menc, diphosphine ligand.
	5. The process of	claim 4, wherein L is selected from the
	group consisting of	. •
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	MeOBIPHEP	(6,6'-Dimethoxybiphenyl-2,2'-diyl)bis- (diphenylphosphine);
	BIPHEMP	(a,6'-Dimethylbiphenyl-2,2'-diyl)bis-
		(diphenylphosphine);
25	BINAP	[(1,\'-Binaphthyl)-2,2'-diyl]bis-
		(diphenylphosphine);
	pTol-BIPHEMP	(6,6'-Dimethylbiphenyl-2,2'-diyl)bis(di-
	-	(p-tolyl)phosphine);
	pAn-MeOBIPHEP	6,6'-Dimethoxy-P,P,P',P'-tetrakis-(4-
30		methoxy-phenyl)-biphenyl-2,2'-bis-
		phosphine;\
	pDMA-MeOBIPHEP	6,6'-Dimethoxy-P,P,P',P'-tetrakis-(4-
		dimethylamino-phenyl)-biphenyl-2,2'-
		bis-phosphine

(6,6'-Dimethoxybiphenyl-2,2'-diyl)-Phenyl-MeOBIPHEP bis(bis-(biphenyl)-phosphine); mToI-BIPHEMP (6,6'-Dimethylbiphenyl-2,2'-diyl)bis(di-(m-tolyl)phosphine); Cy2-MeOBIPHEP P2,P2-Dicyclohexyl-6,6'-dimethoxy-P2',P2'-diphenyl-biphenyl-2,2'-bisphosphine; 2-Furyl2-BIPHEMP P,P-Diphenyl-P',P'-di-2-furyl-(6,6'dimethyl-biphenyl-2,2'-diyl)diphos-10 phine; (3,5-Me,4-MeQ)-MeOBIPHEP 6,6'-Dimethoxy-P,P,P',P'-tetrakis-(dimethyl-4-methoxy-phenyl)-biphenyl-2,2'-bis-phosphine; **DiMeOBIPHEP** (5,5',6,6'-Tetramethoxybiphenyl-2,2'-15 diyl)bis(diphenylphosphine); **TriMeOBIPHEP** (4,4',5,5',6,6'-Hexamethoxybiphenyl-2,2'-diyl)bis(diphenylphosphine); and 2-Furyl-MeOBIPHEP (6,6'-Dimethoxybiphenyl-2,2'-diyl)bis-(di-2-furylphosphine). 20 The process of claim 5, wherein the catalyst is 6. Ru(OAc)<sub>2</sub>(R)-MeOBIPHEP. 7. A process for the manufacture of compounds of the 25 formula  $R^2Q$ NHR1 Ι

wherein R<sup>1</sup> and R<sup>2</sup> are independently an acyl residue of an aromatic carboxylic acid, comprising:

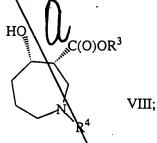
a) microbially reducing a compound of the formula

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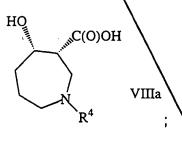
$$C(O)OR^3$$
 $R^4$ 

wherein R3 is lower-alkyl and R4 is a protecting group,

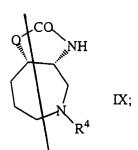
10 to a compound of the formula



b) saponifying the compound of formula VIII to a compound of the 15 formula



c) transforming the compound of formula VIIIa into a compound of 20 the formula



d) hydrolyzing the compound of formula IX into a compound of the formula

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e) acylating the compound of formula X with an aromatic carboxylic acid of the formula R1COOH to a compound of the formula

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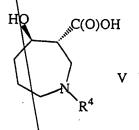
f) acylating the compound of formula XI with an aromatic carboxylic acid or a reactive derivative thereof, to form a compound 15 of the formula

g) cleaving off the protecting group R<sup>4</sup> from the compound of formula XII yielding the compound of formula I

- 8. The process of claim 7, wherein the compound of formula III is reduced using a culture of Hanseniaspora uvarum R 1052.
- 5 9. The process of claim 7, wherein R<sup>1</sup> and R<sup>2</sup> are phydroxybenzoyl.
  - 10. The compounds of the formula

wherein R3 is lower alkyl.

- 11. The compound of claim 10, ethyl (3R,4R)-4-hydroxy-15 azepan-carboxylate hydrochloride.
  - 12. The compound of the formula



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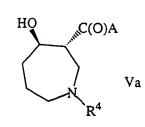
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wherein R4 is a protecting group.

13. The compound of claim 12, (3R,4R)-4-Hydroxy-azepan-1,3-dicarboxylic acid 1-tert.-butyl ester.

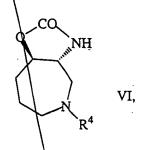
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14. The compound of the formula



5 wherein A is azido or amino and R4 is a protecting group.

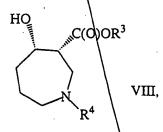
15. The compound of the formula



wherein R4 is a protecting group.

16. The compound of claim 15, (3aR,8aR)-5-tert-Butoxycarbonyl-2-oxo-octahydro-oxazolo(4,b-c)azepine.

17. The compound of the formula



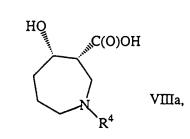
wherein R3 is lower alkyl and R4 is a protecting group.

18. The compound of claim 17, ethyl (3R,4S)-1-(tert-butoxycarbonyl)-4-hydroxy-azepan-3-carboxylate.

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a

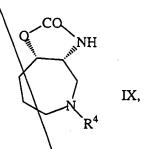
19. The compound of the formula



wherein R is a protecting group.

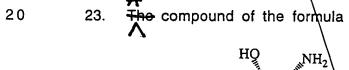
20. The compound of claim 19, (3R,4S)-4-Hydroxy-azepan-1,3-dicarboxylic acid 1-tert-butyl ester.

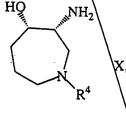
21. The compound of the formula



wherein R4 is a protecting group.

22. The compound of claim 21, tert.Butyl (3aR,8aS)-2-oxo-octahydro-oxazolo(4,b-c)azepine-5-carboxylate.





wherein R4 is a protecting group.

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- 24. The compound of claim 23, tert-Butyl (3R,4S)-3-amino-4-hydroxy-azepan-1-carboxylate.
- 5 25. The compound of the formula

wherein R4 is a protecting group.

26. The compound of claim 25, tert-Butyl (3R,4S)-3-(4-tert-butoxy-benzoylamino)-4-hydroxy-azepan-1-carboxylate.

27. The compound tert-Butyl (3R,4R)-3-(4-tert-butoxy-15 benzoylamino)-4-(4-tert-butoxy-benzoyloxy)-azepan-1-carboxylate.